

## Problem set 1

*Use the material from*

*V.F.Gantmakher "Electrons and Disorder in Solids", Chapter 1*

*A.A. Abrikosov "Fundamentals of Theory of Metals", Chapter 3*

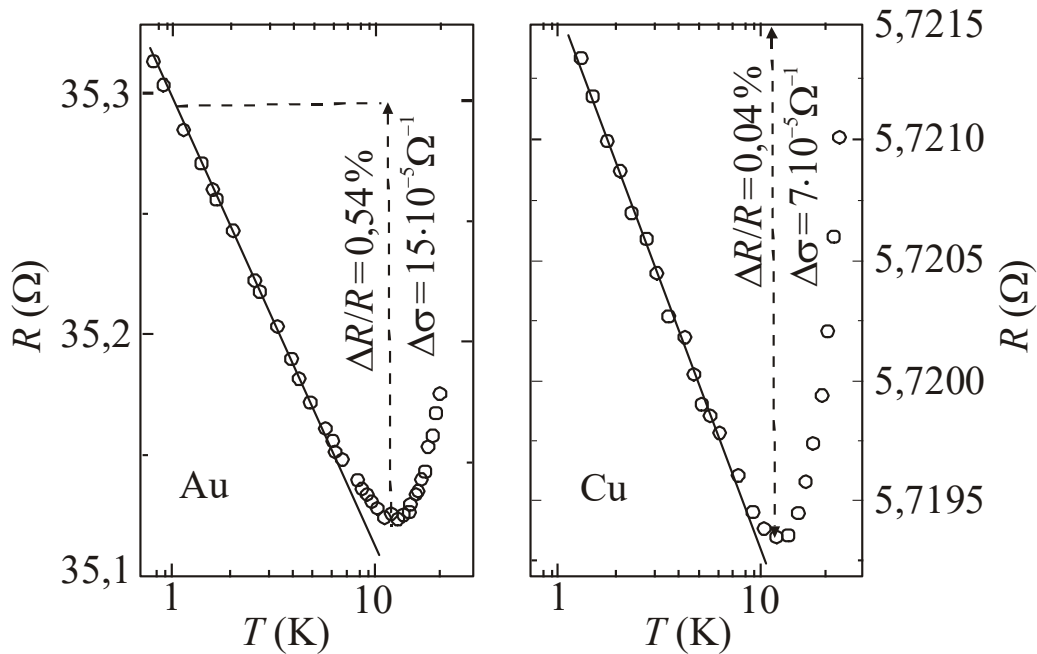
- Derive the expression for electronic diffusion coefficient  $D$  in a metal (consider two- and three-dimensional cases). Derive the Einstein relation between  $D$  and electrical conductivity. Estimate resistivity of a typical metal (take Cu or Au as an example) assuming the mean free path  $\sim 100$  nm.
- Plot schematically temperature dependence of electrical resistivity for a typical metal and discuss its main features in terms of various mechanisms of electronic scattering (impurities, electron-electron and electron-phonon interaction).

## Problem set 2

- Using the weak localization theory, explain the main features of the experimental data shown below

**Au** – S.I. Dorozhkin, *et. al.*, JETP Lett. **36**, 15 (1982)

**Cu** – L. Van der Dreis *et. al.*, PRL **46**, 565 (1981)



- Based on the above data, estimate the electronic mean free paths and the phase breaking lengths in Au and Cu at  $T = 2$  K.

- For both films, sketch the dependence of the resistance on magnetic field at  $T=2$ K for several magnetic field directions.

Prove that the condition  $\Omega\tau \ll 1$  is fulfilled,

where  $\Omega$  is the cyclotron frequency, corresponding to the magnetic field  $B_\phi$ .

- Discuss possible ways of experimental determination of the phase breaking length

### Problem set 3

- Estimate a Coulomb gap in a material with permittivity  $\kappa=10$

(a) in 3D regime with carrier concentration  $10^{16} \text{ cm}^{-3}$

(b) in 2D regime with carrier concentration  $10^{12} \text{ cm}^{-2}$ .

- Consider thin film with thickness 100 nm, permittivity  $\kappa=10$ , concentration of carriers  $10^{18} \text{ cm}^{-3}$  and effective mass  $0.1m_e$ . Estimate crossover temperature when electronic hopping behaviour changes from three-dimensional to two-dimensional regime i.e. when the resistivity behaviour changes from

$$\rho = \rho_0 \exp(T_M / T)^{1/4}$$

to

$$\rho = \rho_0 \exp(T_M / T)^{1/3}$$

.- Derive the expression (or explain the main steps in its derivation) for the screening length given by Eq.5.42 in Gantmakher's book.

Hint: the discussion for two dimensions can be found e.g. on pp.73-74 in Datta's textbook "Electronic transport in mesoscopic systems".

- Show that dimensionless conductance  $y$  defined by Eq.6.1 in Gantmakher's book is the ratio of Thouless energy and mean level spacing for any sample dimensionality.

Discuss the physical meaning of Thouless energy.